	Application No.	Applicant(s)	
Notice of Allowability	10/647,479	YASHIRO ET AL.	
	Examiner	Art Unit	
	Mark H. Paschall	3742	
The MAILING DATE of this communication appearance All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT Report of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this applied or other appropriate communication IGHTS. This application is subject to	plication. If not included will be mailed in due cou	ırse. THIS
1. This communication is responsive to			
2. The allowed claim(s) is/are <u>12-17</u> .			
3.			
Attachment(s) 1. ☑ Notice of References Cited (PTO-892) 2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948) 3. ☐ Information Disclosure Statements (PTO/SB/08), Paper No./Mail Date 4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	5. ☐ Notice of Informal P 6. ☐ Interview Summary Paper No./Mail Dat 7. ☑ Examiner's Amendr 8. ☑ Examiner's Stateme 9. ☐ Other	(PTO-413), te ment/Comment	nce .
	F	Mark Paschall Primary Examiner	

Examiner's Amendment

An examiner's amendment to the record appears below. Should the changes

and/or additions be unacceptable to applicant, an amendment may be filed as provided

by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be

submitted no later than the payment of the issue fee.

The application has been amended as follows:

This application is in condition for allowance except for the presence of claims 1-

11 directed to Group I, non-elected without traverse. Accordingly, claims 1-11 been

cancel

ed.

Claims 12-17 are allowed.

The following is an examiner's statement of reasons for allowance: the prior art of

record does not teach a plasma processing system having a plate shaped electrode and

a plate shaped insulator adjacent to the plate electrode, with a discharge gas source

having inert gas supplied to a first exhaust port and a second discharge exhaust port for

a higher breakdown gas than the first gas, with the second port located further from the

plate electrode than the first gas source.

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Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Koinuma et al, Gibb et al, Tanisaki and Schoumaker are cited for disclosing plasma systems of general interest to the instant invention.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Mark H. Paschall whose telephone number is 571 272-4784. The examiner can normally be reached on 7am - 3pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Robin Evans can be reached on 571-272-4777. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Mark H Paschall
Primary Examiner
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